Single-shot measurement of electron spins in Si/SiGe quantum dots



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Sponsored in part by the Army Research Office and the Laboratory for Physical Sciences, the National Science Foundation, and the United States Department of Defense.

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Silicon has excellent spin coherence properties

I.Weak Spin - Orbit Coupling

Interaction of a particle's spin with its orbital motion

Very weak in Si





2. Small Hyperfine Interaction

Interaction between electron spin and nuclear spin

Zero nuclear moment in ²⁸Si and ³⁰Si

Natural Silicon is nuclear spin-zero abundant (~92%)

C.Tahan,et al, Phys. Rev. B 66, 035314 (2002) R. de Sousa et al., Physical Review B 68, 115322 (2003)



M. Fuechsle, et al. Nat. Nanotech. 5, 502 (2010)



E. P. Nordberg, et al., *Physical Review B 80,* 115331 (2009)



J. R. Prance, et al., appearing in *Phys. Rev. Lett.*



This is a schematic of the Si/SiGe heterostructure that we use in our experiment.Si is grown on the SiGe virtual substrate, followed by a relaxed SiGe buffer layer. The reason we use SiGe instead of pure Si is to strain the Si lattice so that resulted strained Si layer acts as a quantum well which confines electrons to 2–D. The structure is also delta doped with phosphorus so that electrons populate the well without being strongly scattered locally. Finally, we put a silicon cap layer after a second buffer to prevent humidity and water. The material is characterized to have a carrier density of ... and a mobility of...



After we get the material, the device is fabricated first by etching a mesa with 2DEG, which is 45um by 45um large. We etch a small mesa to prevent leakage current between the gate and the 2DEG. Then we deposit Au/Sb as ohmic contact metal. The device is annealed after deposition to allow the metal to diffuse down to the 2DEG to make contact. After that, optical and e-beam gates are put down on the surface of the sample to deplete the 2DEG and form the quantum dot.



• Controllable loading of spin-up and spindown states

• Controlling the tunnel coupling in Si/SiGe double quantum dots

• Single-shot measurement of 2-electron singlet and triplet states







data: 092210

Single shot readout of electron tunneling







data:072910



data: 070710 exported as 4.8 x 3.9 and bjornteckresultsforpaper





data: 081110 exported as 4.5 x 2.8



data: bjornteckresultsforpaper 5x4



WHY





data: bjornteckresultsforpaper 6.2x3.7,6.2x3



NWYIY









data: 111308 and 111408



plots from: TunnelCouplingAnalysisNew



J = 4t2/EC Ec~2.3meV t: ~3.3ueV to ~45ueV thus J: 19 neV to 3.5 ueV SWAP time = hbar*pi/J thus SWAP time: 110 ns to 590 ps

plots from: TunnelCouplingAnalysisNew



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Singlet and triplet states in a 2-electron double quantum dot















Acknowledgments Wisconsin: Thanks **Christie Simmons** Madhu Thalakulam Jon Prance Zhan Shi Robert Mohr Bjorn Van Bael Ben Rosemeyer Don Savage Max Lagally qc.physics.<mark>wisc</mark>.edu Robert Joynt Mark Friesen qc.physics.wisc.edu Susan Coppersmith <u>Delft:</u> Lars Schreiber Lieven Vandersypen



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Interpretation of triplet lifetime at B = 0

For small exchange (J), hyperfine coupling to nuclei (h_x) should drive singlet-triplet mixing [1] Large J reduces the effectiveness of hyperfine mixing



Outline

• Single-shot readout of single spins in Si/SiGe quantum dots

• Controllable loading of spin-up and spindown states

• Controlling the tunnel coupling in Si/SiGe double quantum dots

• Single-shot measurement of 2-electron singlet and triplet states

• Controlling the singlet-triplet energy splitting in Si/SiGe double quantum dots.













Theoretical simulation performed using coupled rate equation model:

$$\frac{dp_S}{dt} = (1 - \sum_{i=S,T} p_i)\Gamma_S^L \qquad \qquad \frac{dp_{T_k}}{dt} = (1 - \sum_{i=S,T} p_i)\Gamma_{T_k}^L \qquad (k = -, 0, +)$$

Z. Shi et al., ArXiv: 1109.0511





Triplet state loads and unloads much faster than singlet, providing a way to perform spectroscopy and lifetime measurement.



Then the next thing we do is we sit at a certain field, say 1.5 T, and we keep the unloading level constant and change the loading level, and see how the loading and unloading rate change as a function of loading level. Here is an example. At 1.5 T the ground state is still singlet, and it is slow. As we increase the loading depth we see two peaks in the loading rate, which we believe is the T- state and T0 state being pulsed down the fermi level. And the unloading rate does not change with the loading level, which indicates the electron always unload from the same state, the singlet. Since the loading time here is 600ms, which is relatively long, even if we load the T- and T0, they decay to the singlet quickly so the electron always unloads from the singlet. So a natural thought is if we make the load time short so that electron loading to the T-and T0 doesn't decay, will we see a change in the unloading rate?

Then, we change the loading time to be 300ms and do the same thing, we discover that there is a little bump in the unloading rate when we preferably load T-. Then, if we make the loading time 40ms, we see a peak in the unloading rate when we load the T-. The decay from T- to S is a T1 process, since there is a big difference in the unloading rate between S and T-, if we sit at a loading level

where we preferably load T- and we change the loading time and see how the unloading rate change, we should be able to get T1



So we sit at a loading level of 140mV, we vary the loading time and see how the unloading rate change as a function of loading time. Here we see the loading rate doesn't change much with the loading time but the unloading rate decays exponentially with the increase of loading time. And the fit gives us the characteristic time of this decay, 141ms, which we believe is T1.



S. N. Coppersmith and collaborators: new spin qubit proposal using (2,1)-(1,2) electron occupation states in a double quantum dot.





Conclusions

• The spin state of a two-electron double dot was read out in real-time

• Statistical analysis of the real-time data gives the lifetime of the (1,1) triplet states.

• The lifetime of the T. (1,1) state was seen to increase with applied magnetic field, reaching ~6s at 1T.

• At B = 0T, the triplet lifetime is ~10ms.

• We attribute the long, zero-field lifetime to a strong coupling between the dots. This suppresses the effect of hyperfine induced singlet-triplet mixing close to the (1,1)-(0,2) transition.

• The singlet-triplet splitting is tunable by gate voltages in Si/SiGe double quantum dots







Event detection using the real wavelet transformation

Double dot charge stability diagram



- Measure dI_{QPC}/dV to identify charge transitions as a function of the left (L) and right (R) gate voltages
- Black and white lines indicate charge transitions on the double quantum dot

data: 101108





